Synthesis of Difluoroenoxysilanes from Acylsilanes and Trifluoromethyltrimethylsilane (TFMTMS). Dramatic Effect of the Catalytic Fluoride Source

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Difluoroenoxysilanes are produced in high yield by catalytic fluoride activation of a mixture of TFMTMS and an acylsilane: Tetrabutylammonium difluorotriphenylstannate is an excellent catalyst whereas tetrabutylammonium fluoride leads directly to the aldol product corresponding to the difluoromethyl ketone. Some one-pot applications illustrate the usefulness of this methodology.

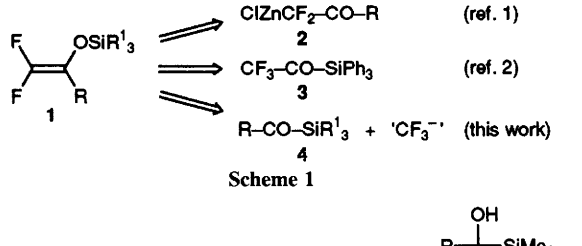
Difluoroenoxysilanes **1** (Scheme 1) are useful difluoroenolate equivalents first prepared by silylation of zinc difluoroenolates **2**,[1] and more recently by the addition of an organometallic reagent to trifluoroacetyltriphenylsilane **3**,[2] in the latter method, all applications reported involved trifluoroacetyltriphenylsilane **3** (R^1 = Ph).[3]

While studying the properties of acylsilanes,[4] we have used the Brook rearrangement to develop new organofluorosilicon intermediates.[5–9] Having prepared higher perfluoroenoxysilane analogues by a one-pot sequence,[7] we studied the synthesis of difluoroenoxysilane **1** by a similar strategy, more versatile than that from **3** allowing variation of both acyl and silyl part of **4**. As the trifluoromethyl anion source we chose trifluoromethyltrimethylsilane[10] (TFMTMS) under fluoride activation.[11]

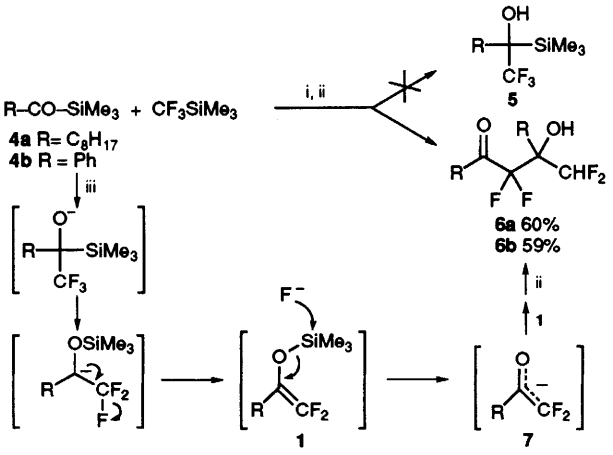
A mixture of **4a** and TFMTMS (1.2 equiv.) was treated with 0.15 molar equivalent of tetrabutylammonium fluoride (TBAF) in THF at low temperature (−78 °C) in order to attempt to isolate the alcohol **5** (Scheme 2). Neither **5** nor the expected **1a** was detected, but the reaction gave cleanly, even at 0 °C, a product with spectral features consistent with the structure **6**,† which derived formally from aldol condensation of the corresponding difluoromethyl ketone, in 60% yield. A difluoroenolate is probably generated *in situ* and the path depicted in Scheme 2 is a tentative explanation of the formation of **6**. The enoxysilane **1**, formed after the Brook rearrangement, would be immediately converted into enolate **7** under fluoride attack (*vide infra*). Thus **1** would act as a nucleophile (difluoroenolate equivalent) as well as an electrophilic substrate leading to **6**. This dual behaviour has already been observed by us for higher homologues[7] and by Nakai *et al.* for perfluoroenolate.[12]

To avoid this self condensation, we needed to inhibit the nucleophilic activation of **1** by the fluoride anion by using a less nucleophilic source of fluoride. Tetrabutylammonium difluorotriphenylstannate (DFTPS) ($Bu_4N^+Ph_3SnF_2^-$) has recently been reported to be less nucleophilic than TBAF,[13] so we prepared and used this salt and were gratified to obtain the expected difluoroenoxysilane very cleanly and conveniently (0.01 equiv. of DFTPS, 0 °C, 1 h) (Scheme 3 and Table 1). Starting from the acyltrimethylsilanes **4a,b** the enoxysilanes **1a,b** were formed in high yields (entries 1 and 2) but were too easily hydrolysed during work-up and purification to be isolated as pure materials. However, the *tert*-butyldimethylsilyl analogues **1c,d** were isolated in high yield (entries 3 and 4). This reaction can be carried out in THF, diethyl ether and even dichloromethane with an equal efficiency. So one-pot reactions under nucleophilic or Lewis acid activation can be expected. To assess the mechanism claimed in Scheme 2, a catalytic amount of TBAF (0.2 equiv.) was added to the difluoroenoxysilane **1b** generated *in situ* from **4b** and TFMTMS in diethyl ether. The condensation compound **6b** was indeed the major product confirming the crucial importance of the fluoride source.

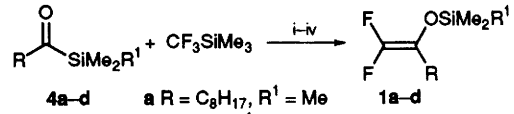
The one-pot reactions shown in Scheme 4 and 5 illustrate the potential of this methology, although they would need further optimization. Dilute acidic hydrolysis converted **1a** quantitatively (GC, NMR) into the corresponding difluoromethylketone **8**. The *tert*-butyldimethylsilyl derivative **1c**



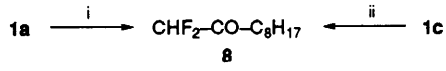
Scheme 1



Scheme 2 *Reagents and conditions*: i, TBAF (0.15 equiv.) THF, −78 °C or 0 °C; ii, H_2O; iii, F^-.



Scheme 3 *Reagents and conditions*: i–iv, $Bu_4N^+Ph_3SnF_2^-$ (cat), solvent as entries 1–4, Table 1.

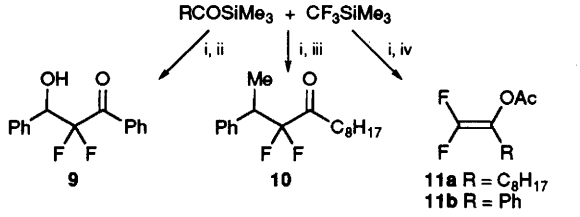


Scheme 4 *Reagents*: i, aq. HCl (2 mol dm^{-3}), THF; ii, TBAF, THF–H_2O.

Table 1 Synthesis of difluoroenoxysilanes

Entry	Acylsilane	DFTPS (equiv.)	Conditions solvent, temp./°C, time/h	Product[a]
1	**4a**	0.01	THF, −78 to −20, 4	**1a** 44 (quant.)
2	**4b**	0.01	CH_2Cl_2, 0, 1	**1b** (quant.)
3	**4c**	0.25	THF, −78 to −20, 1	**1c** 75
4	**4d**	0.25	THF, −78 to −20, 1	**1d** 79

[a] Isolated yield. GC or NMR estimated yield in parenthesis.



Scheme 5 *Reagents and conditions*: i, DFTPS (0.01 equiv.), CH_2Cl_2, 0 °C, 30 min.; ii, $TiCl_4$ (1.5 equiv.), PhCHO (1.2 equiv.), −78 °C, then room temp., 20 h, 71%; iii, $ZnBr_2$ (1.2 equiv.) PhCH(Me)Br, 12 h, 50%; iv, $ZnBr_2$ (1.2 equiv.), MeCOCl, 12 h, **11a**: 60%, **11b**: 61%.

needed a treatment by TBAF in wet THF to give **8**. The fair isolated yield of **8** (57%) was due to their partial hydration and the small scale of the experiment. The Mukayiama aldol reaction was performed by adding $TiCl_4$ and benzaldehyde to the crude solution of **1b** cooled at −78 °C. After 20 hours stirring at room temperature, the corresponding aldol **9**,‡ was isolated in 71% overall yield. Addition of $ZnBr_2$ and 1-bromo-1-phenylethane to **1a** prepared in CH_2Cl_2 gave the corresponding benzylated difluoro derivative **10**,§ in 50% overall isolated yield. Addition of $ZnBr_2$ and acetyl chloride to the crude solution of **1a** or **1b** in CH_2Cl_2 gave exclusively the O-acylated corresponding product **11a** and **b** as it has already been observed.[1]

In summary, the anionic trifluoromethylation of acylsilanes using TFMTMS is a new, efficient and versatile method to synthesize difluoroenoxysilanes which can be used *in situ* to prepare various difluoromethylene compounds. This study emphasizes the importance of the choice of the activating fluoride and reveals the electrophilic character of the difluoroenoxysilane.

We thank the Ministere de l'Enscignement Superieur et de la Recherche for financial support, and Olivier Lefebvre for his assistance.

Received, 20th May 1994; Com. 4/03017F

Footnotes

† **6a**: ^{1}H NMR ($CDCl_3$; 250 MHz; *J*/Hz) δ 1.84 (t, $^3J_{HH}$ 8, CH_2COH), 2.76 (td, J_{HH} 7, $^4J_{HF}$ 1.3, CH_2CO), 3.64 (s, OH), 5.89 (td, $^2J_{HF}$ 55, $^4J_{HF}$ 1.2, CHF_2); ^{13}C NMR ($CDCl_3$; 62.89 MHz, *J*/Hz) δ 76.7 (m, COH), 114.8 (t, $^1J_{CF}$ 250, CHF_2), 113.5 (t, $^1J_{CF}$ 264, CF_2), 202.9 (t, $^2J_{CF}$ 29, CO); ^{19}F NMR ($CDCl_3$, 235.36 MHz; *J*/Hz) δ/$CFCl_3$ − 115.6 (d, $^2J_{FF}$ 282, 1F, CF_2), −117.6 (d, $^2J_{FF}$ 282, 1F, CF_2), −129.8 (dd, $^2J_{FF}$ 290, $^2J_{HF}$ 54, CHF), −131.4 (dd, $^2J_{FF}$ 290, $^2J_{HF}$ 54, CHF); *m*/*z* (70 ev) 159 (M^+ −225, 1), 141 (100), 71 (22), 57 (33), 55 (17). Found: C, 62.50; H, 9.82. Calc: C, 62.48; H, 9.44%).

‡ **9**: ^{1}H NMR ($CDCl_3$; 250 MHz; J/Hz) δ 3.10 (d, $^3J_{HH}$ 4.6, OH), 5.27 (dt, $^3J_{HF}$ 18.6, $^3J_{HH}$ = $3J_{HF}$, 4.6, CH); ^{13}C NMR ($CDCl_3$; 62.89 MHz; J/Hz) δ 73.4 (dd, $^2J_{CF}$ 27.6, $^2J_{CF}$ 21.7, CH) 118 (dd, $^1J_{CF}$ 263.8, $^1J_{CF}$ 258, CF_2), 191 (t, $^2J_{CF}$ 29.3, CO); ^{19}F NMR ($CDCl_3$, 235.36 MHz J/Hz) δ/$CFCl_3$ − 108. 1 (dd, $^2J_{FF}$ 292, $^3J_{HF}$ 4.6, CF_2), −116.8 (dd, $^2J_{FF}$ 292, $^2J_{HF}$ 18.6, CF_2).

§ **10**: ^{1}H NMR ($CDCl_3$; 250 MHz; *J*/Hz) δ 1.44 (d, $^3J_{HH}$ 7, CH_3CH), 2.14 (dtm, J_{AB} 18.6, $^3J_{HH}$ 6.5, CH_2CO), 2.42 (dtm, J_{AB} 18.6, $^3J_{HH}$ 6.5, CH_2CO), 3.49 (m, CH), 7.08–7.36 (m, Ar); ^{13}C NMR ($CDCl_3$; 62.89 MHz; *J*/Hz) δ 13.6 (*C*H_3CH), 14.1 (CH_3), 22.3, 22.6, 28.7, 29.0, 29.1, 31.7, 37.8 (CH_2), 43.0 (t, $^2J_{CF}$ 22.5, CH), 127.8–129.0 (Ar), 202.5 (t, $^2J_{CF}$ 30, CO); ^{19}F NMR ($CDCl_3$, 235.36 MHz; *J*/Hz) δ/$CFCl_3$ − 109.2 (dd, *J* 259, $^3J_{FH}$ 13, 1F, CF_2), −117.4 (dd, *J* 259, $^3J_{FH}$ 20, 1F, CF_2), *m*/*z* (70 ev) 296 (M^+, 17), 141 (100), 105 (21), 71 (88), 57 (74). (Found: C, 73.09; H, 9.11. Calc: C, 72.94; H, 8.84%).

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